

INTERNATIONAL
GEMOLOGICAL
INSTITUTE

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LABORATORY GROWN DIAMOND REPORT

October 9, 2025

IGI Report Number

Description

Shape and Cutting Style

Measurements

GRADING RESULTS

Carat Weight

Color Grade

Clarity Grade

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence

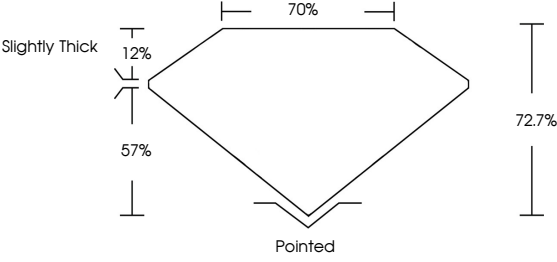
Inscription(s)

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

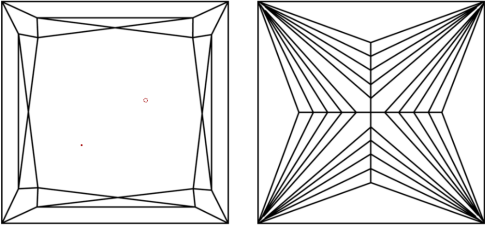
LG729572198

Report verification at [igi.org](https://www.igi.org)

PROPORTIONS



CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics.
Green symbols indicate external characteristics.

COLOR


D E F G H I J Faint Very Light Light

CLARITY


FL IF VS 1-2 VS 1-2 SI 1-2 I 1-3

Flawless Internally Flawless Very Very Slightly Included Very Slightly Included Slightly Included Included

Sample Image Used



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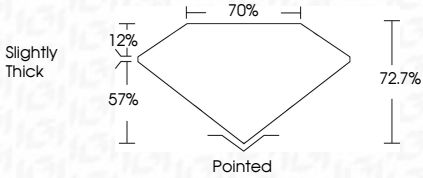
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PROPORTIONS





IGI

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PRINCESS CUT

7.57 X 7.46 X 5.42 MM

2.73 CARATS

E

VVS 2

72.7%

70%

Slightly Thick

Pointed



EXCELLENT

EXCELLENT

NONE


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